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(54) **PROTECTIVE LAYERS FOR SPUTTER COATED ARTICLE**

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(72) Inventor: **O'SHAUGHNESSY, Dennis, J.**

Allison Park, PA 15101 (US)

(30) Priority: **16.06.1999 US 334193**

(74) Representative: **Polypatent**

Postfach 40 02 43

51410 Bergisch Gladbach (DE)

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(73) Proprietor: **PPG Industries Ohio, Inc.**

Cleveland, OH 44111 (US)

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Description

[0001] This invention relates, in general, to protective layers for sputter coated articles such as coated or uncoated glass or transparent. Such articles with the protective layers are shippable, heat treatable, can have low emissivity coating or coatings. The invention also relates to the coated articles and to the use of the coated articles.

[0002] U.S. Patent No. 4,610,771 ("U.S.P.N. '771") discloses an antireflective sputtered metal oxide film deposited using a zinc/tin alloy target. U.S.P.N. '771 in column 3, line 26, to column 4, line 12, discusses the use of the alloy target to deposit a zinc stannate film having, in general, oxides of zinc and tin preferably in proportions of 10 to 90 percent zinc and 90 to 10 percent tin.

[0003] Although the zinc/tin alloy target disclosed in U.S.P.N. '771 to deposit the zinc stannate film is acceptable, there are limitations. More particularly, in a low E coating such as the type described in U.S.P.N. '771, an infrared reflecting metal film or layer, e.g., silver is deposited on the zinc stannate film. A silver film deposited on a sputtered zinc stannate film has a higher electrical resistivity and higher emissivity than a silver film deposited on a sputtered zinc oxide film or layer. More particularly, U.S. Patent No. 5,821,001 ("U.S.P.N. '001") discloses a silver film deposited on a zinc oxide film; the atoms of the silver film deposit in a form characterized by a low electrical resistivity which provides the silver film with a low emissivity. In depositing the zinc oxide film the process parameters are selected to deposit a zinc oxide layer with a suitable crystallinity or preferential crystal growth for favorably affecting deposition of the silver atoms of the silver film.

[0004] Sputtering zinc in a reactive atmosphere, e.g., oxygen, to provide a zinc oxide film over which a silver film having a low electrical resistivity is deposited has drawbacks. For example, it is difficult to reactively sputter a pure zinc target, i.e., a target of about 100% zinc metal, in a reactive atmosphere such as oxygen for reasons discussed in more detail below.

[0005] U.S.P.N. '001 also discloses a heat treatable low emissivity film. The thickness of the primer layers, e.g., titanium films, may be increased to provide enhanced mechanical durability, i.e., improve shear resistance. The shear resistance test consists of applying 20 successive strokes of a cloth wetted with deionized water against the coated surface of glass, followed by visual examination of the tested area. Depending on the appearance of the tested area, letter grades of D-, D, D+...A, A+ are assigned to the coating; then, for numerical analysis, assignments of 5 to D-, 10 to D, 55 to A, and 60 to A+ are made. If a coating shows no signs of shear, not even barely visible scratches, then it receives a maximum rating of 60. Coatings that display uniform shear and delamination at any interface of the multilayer coating within the test area receive a failing rating of zero. Other levels of performance receive intermediate scores. This method of coating durability characterization has been found to correlate well with field performance of the coating. The drawback with using thick primer layers is that the coating stack after heating, e.g., glass tempering or glass bending operations, is likely to have a hazy appearance when viewed using a dark room, flood-light haze test. In the dark room, floodlight haze test, the coated specimen is viewed in reflection in a dark room at various viewing angles relative to a spotlight, in order to find the geometry yielding maximum scattering of light, or, in other words, haze, possible from the coating.

[0006] If there is no geometry that can make haze observable, an A+ rating is assigned to the sample. Very poor samples receive D-. For purposes of numerical analysis, the letter grades are given values of 5 to 60, as described above for the shear test. Lower haze corresponds to higher numerical values.

[0007] EP-A-803 481 refers to high transmittance, low emissivity coated articles wherein a transparent substrate is coated with a multilayer coating stack including a protective hard overcoat of titanium oxide.

[0008] From GB-A-2 311 540 a coated sheet is known for use in a laminated assembly having a high level of luminous transmission and low energy transmission. The five layer multi-coated substrate has layers from specific materials within specific thickness limits and specific ratios in the respective thickness of certain layers. It is disclosed to apply a protective layer which shields the coating stack and provides improved chemical and/or mechanical durability with little or no consequential change of its optical properties. As protective materials are mentioned oxides, nitrides and oxynitrides of silicon and SiO₂. As sacrificial materials for the reflective metal layer titanium and zinc are disclosed.

[0009] US-A-4,902,580 discloses multilayer coated articles having high transmittance in the visible wavelength range, low emissivity coatings. A protective overcoat is disclosed prepared from alloys of iron or nickel, titanium, titanium oxide.

[0010] US-A-5,059,295 refers to a method of making low emissivity windows. With regard to the protective overcoat the use of alloys of iron or nickel and titanium/titanium oxide is disclosed.

[0011] WO 99/58763 which is a document under Article 54(3) EPC refers to a multilayer coated articles having high transmittance in the visible wavelength range and low emissivity. To provide chemical and mechanical durability for the coating stack a protective overcoat is applied. As useful materials are disclosed titanium, titanium dioxide, silicon oxide, silicon dioxide, silicon aluminum nitride. If desired more than one protective film may be used.

[0012] As can be appreciated by those skilled in the art of making sputtered coatings, it would be advantageous to provide a zinc target that may be sputtered in a reactive atmosphere without the drawbacks of the presently available zinc targets and to provide low emissivity coated articles that have mechanical durability so that the coated article may be shipped and subsequently heated without the heated coating having haze.

[0013] The above mentioned object is attained by a coated article according to the present invention, the coated article comprising:

(i) a substrate;

(ii) a first dielectric layer sputter deposited over the substrate (i), the layer (ii) comprising:

(iia) a first zinc stannate film deposited over the substrate (i) having zinc in weight percent range of equal to and greater than 10 and equal to and less than 90, and tin in the weight percent range of equal to and less than 90 and equal to and greater than 10, and

(iib) an electrical enhancing film deposited over the zinc stannate film (iia), the electrical enhancing film selected from the group of films consisting of zinc oxide, tin oxide film sputter deposited from a target having from 0.5 to 9.5 weight percent tin and from 99.5 to 90.5 weight percent zinc and a second zinc stannate film, wherein the composition of the first zinc stannate film (ia) is at least about 5 weight percent different than the composition of the second zinc stannate film, and

(iii) at least one infrared reflective layer over the first dielectric layer (ii);

(iv) optionally a first metal primer layer over the first infrared reflective layer (iii);

(v) optionally a second dielectric layer over a first metal primer layer (iv); and

(vi) at least one protective layer consisting of two films, wherein one film is selected from metals or silicon and the other film is selected from metal-oxy-or silicon-oxy-materials, wherein one of the films is deposited first with the other film deposited over the first deposited film, and where the metal is the same or different and selected from titanium, zirconium, niobium, tantalum, chromium, nickel and alloys thereof, and where the oxy-materials are selected from titanium oxides, titanium oxynitride, zirconium oxides, zirconium oxynitride, niobium oxides, niobium oxynitride, tantalum oxides, tantalum oxynitride, chromic oxides, chromic oxynitride, nickel oxide, nickel oxynitride, silicon oxide, silicon dioxide, silicon aluminium nitride.

[0014] Disclosed is a sputter cathode target having tin preferably in an amount greater than zero and less than 10 weight percent of the total weight of the target material, and zinc in an amount preferably less than 100 weight percent and more than 90 weight percent of the total weight of the target material. Hereafter, unless indicated otherwise, the term "weight percent" means the weight percent of the total weight of the target material.

[0015] As used herein, "a zinc stannate film," e.g., of the type discussed in U.S.P.N. '771 is an oxide of an alloy of zinc and tin. The cathode used is made of an alloy of zinc and tin. A "zinc oxide, tin oxide film," is a film having oxides of tin and zinc. The cathode used to sputter the zinc oxide, tin oxide film is made of zinc having additions of tin as is discussed in detail below.

[0016] In one embodiment of the invention a coating stack has a zinc stannate film deposited on a glass substrate, a zinc oxide, tin oxide film deposited on the zinc stannate film; an infrared reflecting film, e.g., silver, deposited on the zinc oxide, tin oxide film; a primer layer, e.g., a titanium metal film, deposited on the infrared reflecting film; a zinc oxide, tin oxide film deposited on the primer film, a zinc stannate film deposited on the zinc oxide, tin oxide film; an infrared reflecting film deposited on the zinc stannate film; a primer layer deposited on the infrared reflecting layer; a zinc oxide, tin oxide film deposited on the primer layer, a zinc stannate film deposited on the zinc oxide, tin oxide film; and a protective layer. In another embodiment of the invention, a zinc oxide film is used in place of the zinc oxide, tin oxide film. In a further embodiment of the invention, a zinc stannate film is used in place of the zinc oxide, tin oxide film. When a zinc stannate film is used in place of the zinc oxide, tin oxide film, the zinc stannate films differ in composition by at least 5 weight percent. For example, when one of the zinc stannate films is about 50 weight percent zinc and 50 weight percent tin, the other zinc stannate film is about 10-45 or 55-90 weight percent zinc and 55-90 or 45-10 weight percent tin. In a still further embodiment of the invention, a first deposited zinc stannate film is 50 ± 10 weight percent zinc and 50 ± 10 weight percent tin. The second deposited or overlying zinc stannate film has tin equal to or greater than 10 weight percent and less than 40 weight percent and preferably 20 weight percent, and has zinc equal to or less than 90 weight percent and greater than 60 weight percent and preferably 80 weight percent. Overlying zinc stannate films having 90 weight percent zinc and 10 weight percent tin have been used.

[0017] Another aspect of the present invention is the composition or films of the protective layer. Of course, the protective layer can be for any multi-layered stack with one or more antireflective layers on a substrate. This multi-layered stack has at least one layer of at least one infrared reflecting film which can be preceded on the near side towards the substrate by one or more dielectric and/or zinc- and/or tin-containing films and can be followed on the side away from the substrate by one or more layers of one or more dielectric and/or zinc- and/or tin-containing films and/or a primer layer. This is also the type of multi-layered stack for the protective layer. Any zinc- and/or tin-containing films can be zinc oxides or tin oxides or the zinc stannates like those in Patents '771 and '001. The protective layer is in principle either a metal film or silicon film or metal oxy-material film or silicon oxy-material film or both. The metal oxy-material or

silicon oxy-material film is either or both metal oxide or silicon oxides films or metal oxynitride or silicon oxynitride films. These metal, metal oxide and metal oxynitride films have one or more metals that are the same or different from metal film to metal oxide or oxynitride film where the metals are those transition metals of Groups, 4, 5, and 10 of the Periodic Table of Elements for the Revised Chemical Element Group Notation having upto 18 groups and alloys thereof that are capable of being sputtered coated. In detail, the protective layer is described above in context with the coated article according to the present invention. For the protective layer the order can be metal film and metal oxide or oxynitride film or the reverse. The protective layer can be the outermost layer on the multi-layered stack but it only needs to be in a position in the multi-layered stack where it can perform the protective function for providing some chemical and/or mechanical durability to the multi-layered stack. Hence there can be additional film or coating layers over the protective layer if desired.

[0018] The above-described coating stack has mechanical and chemical durability. The coatings of the instant invention in addition to having mechanical and chemical durability which make them acceptable for shipment can be heat treated with the heat treated coating having reduced haze. The reduction in haze after heating is accomplished by selecting metal primer thicknesses which is discussed below. The procedure for determining haze was discussed above. As used herein a reduction in haze is a numerical increase of about 10. An advantage of the coatings of the instant invention is that a coating of the invention may be deposited on a substrate, the coated substrate shipped to a fabricating facility where the coated substrate is heat-treated, e.g., heated to temperatures up to about 1350°F (732°C). The coating of the invention has particular application in the making of solar control automotive windshields. Sheets of glass having a low emissivity coating of the invention are coated in one facility and then shipped to another facility where the coated glass sheet is processed, e.g., into an automobile windshield.

[0019] For a full appreciation of the various embodiments of the invention, the embodiments will be discussed separately and then combined. The first embodiment of the invention to be discussed is the use of a zinc cathode having low amounts of tin to improve the deposition of zinc oxide films and the benefits of a zinc oxide film having low amounts of tin.

[0020] The embodiments of the invention relating to zinc sputtering target having low amounts of tin and to a method of reactively sputtering such zinc targets to sputter deposit a zinc oxide, tin oxide film will be discussed. As will be appreciated, the invention contemplates using the target of the instant invention to deposit a zinc oxide, tin oxide film over or under an infrared reflective film, e.g., gold, silver or aluminum film, other metal films, e.g., primer films such as a titanium metal, or ceramic-films, or other dielectric films.

[0021] The sputtering cathode target in one embodiment of the invention has greater than zero weight percent and less than 10 weight percent tin, and less than 100 weight percent and more than 90 weight percent zinc to improve the emissivity of an infrared reflective film, e.g., a silver film, deposited on the zinc oxide, tin oxide film and to improve the sputtering of the zinc cathode target having low amounts of tin. The cathode target of the instant invention may also be defined as having greater than 0 and less than 10 weight percent tin with the majority of the balance zinc, or as having less than 100 weight percent and more than 90 weight percent zinc with the majority of the balance tin. Before discussing this embodiment of the invention, the drawbacks and/or limitations of reactively sputtering a zinc cathode target without tin and limitations of zinc oxide films deposited using such cathodes are discussed for a better appreciation of the invention.

[0022] Typically, a metal target is reactively sputtered in a gas such as oxygen, or gas mixture of oxygen with other gases such as nitrogen, argon or helium. Sputtering in a gas mixture will result in a higher sputtering rate for a stable process but requires more control to maintain the process stability, e.g., requires controlling flow rate of two gases. Because of the higher sputtering rate, it is preferred to sputter in a gas mixture rather than in oxygen alone. In either case the resulting coating is a metal oxide, e.g., zinc oxide when a zinc target is used.

[0023] Zinc oxide is a common dielectric material that is used as a high refractive index film in coating stacks having low emissivity. In the flat glass industry these coatings are usually applied by horizontal vacuum coaters using high power supplied from a direct current source to energize cathodes that sputter layers onto glass substrates. Higher coater throughput requires higher power density to the cathode target. This in turn increases the tendency for the targets to arc, particularly during reactive sputtering.

[0024] During reactive sputtering the frequency of arcing of the zinc cathode target increases with time, and debris in the form of powder and flakes builds up on the target surface and adjacent areas. Debris in the form of powders, flakes and splatter eventually falls onto the surface of the substrate being coated resulting in unacceptable coated product. Further the arcing increases to a point where the process becomes unstable. In addition, areas of the target surface have a tendency to blacken over time. These blackened areas are nonconductive, thus limiting the sputtering rate and leading to non-uniformity in the coating.

[0025] The arcing and debris buildup to some degree may be reduced by periodic sputter cleaning as is known by those skilled in the art of sputter coating. One technique for sputter cleaning is to periodically sputter the targets for a certain time period in an inert gas, such as argon or helium, which sputters the target as a metal. Sputter cleaning to some degree removes the oxide buildup on the target surface that causes arcing. The black areas on the target may not be reduced by sputter cleaning. The debris and arcing, however, continually degrade the target, and after a period of time, the coater downtime increases and, consequently, there is less production time for the coater. Zinc targets

because of their tendency to frequently arc during sputtering are difficult to sputter clean and require longer and more frequent cleaning.

5 [0026] In the practice of the invention, tin is added to a zinc target to reduce if not eliminate the above drawbacks, e.g., reduce the amount of flaking debris, reduce powdery buildup on the target, minimize arcing, and minimize, if not eliminate, blackening of the target surface areas. The amount of debris and degrading of the zinc target of the instant invention is considerably less with time than for a pure zinc target. As a result, less periodic target cleaning is required with less duration of the cleaning in an inert gas.

10 [0027] As previously discussed, U.S.P.N. '771 discloses a zinc-tin alloy target to deposit a zinc stannate film, i.e., an oxide of a zinc tin alloy having 10 to 90 weight percent zinc and 90-10 weight percent tin. The zinc-tin alloy cathode target of U.S.P.N. '771 provides a zinc stannate film that has better chemical durability than a zinc oxide film. Further, the zinc-tin alloy cathode target has less arcing and minimal debris buildup, e.g., there is no measurable powder buildup. As is well-known in the art of sputter coating, zinc oxide films readily dissolve in acid and base solutions; zinc stannate films have reduced solubility in acid or base.

15 [0028] Although the properties of the zinc oxide, tin oxide film of the instant invention have not been studied in great detail, it is believed that the following will occur. As the tin approaches zero weight percent, the chemical durability of the deposited film decreases, and the problems associated with sputtering a zinc target in a reactive atmosphere increase. As the weight percent of tin approaches ten, the chemical durability of the zinc oxide film increases, and the problems associated with sputtering a zinc target in a reactive atmosphere decrease. The electrical resistivity of a silver film deposited on the zinc oxide, tin oxide film is expected to be similar to a silver film deposited on a zinc oxide film. In the practice of this embodiment of the invention, a zinc target having tin greater than zero and less than ten weight percent is a useable range; 0.5 to 9.5 weight percent of tin is a practical range; 4 to 8.5 weight percent of tin is a preferred range, and 5 to 9.5 weight percent of tin is a more preferred range. The weight percent of tin and zinc in a zinc oxide, tin oxide film is expected to be similar to the weight percent of zinc and tin in the target.

20 [0029] As can now be appreciated, as the weight percent of tin in the zinc cathode increases, the chemical durability of the deposited film is expected to increase. Further, the crystalline structure of the zinc oxide film having tin in weight percents greater than zero and less than ten is similar if not identical to the crystalline structure of zinc oxide film having zero weight percent of tin. Further, a zinc stannate film having 60-90 weight percent zinc and 10-40 weight percent tin have similar crystalline structures as zinc oxide. Therefore, it is expected that emissivity of silver film deposited on a zinc oxide film will be similar to a silver film deposited on a zinc stannate film having 60-90 weight percent zinc and 10-40 weight percent tin. At values of less than 60 weight percent zinc, the crystalline structure starts to change and the emissivity and resistivity start to increase. Transmission Electron Microscopy has shown a weak zinc oxide electron diffraction pattern for a zinc stannate film having 66 weight percent zinc and 34 weight percent tin, and an amorphous structure for zinc stannate film having 47. weight percent zinc and 53 weight percent tin.

25 [0030] The coated articles disclosed in U.S.P.N. '001 and U.S. Patent Application Serial No. 09/023,746 filed February 13, 1998, in the names of Mehran Arbab, Russell C. Criss, Gary J. Marietti and Paul A. Medwick for "Coated Articles" (hereinafter "U.S.P.A. No. 09/023,746") may be made practicing this embodiment of the instant invention which includes but is not limited to sputtering a cathode target having 92 weight percent zinc and 8 weight percent tin in an atmosphere having more than 75% oxygen and the remainder argon. Further, problems discussed above associated with sputtering a zinc target are expected to be minimized if not eliminated.

30 [0031] The discussion will now be directed to improving chemical durability of the coating stack, reduction of haze of the coating stack and decreased emissivity of the infrared reflective metal, e.g., silver. "chemical durability" means the coating is not readily attacked by acid or base solutions. Reference may be had to U.S.P.N.'s. '001 and '771 for a discussion on chemical durability. The test for haze was discussed above.

35 [0032] From the above discussion, the emissivity of the silver film may be reduced by depositing the silver layer on a zinc oxide film; a zinc oxide, tin oxide film or a zinc stannate film having zinc in the range of 60 to 90 weight percent and tin in the range of 10 to 40 weight percent. Further, from the above discussion, chemical durability of a layer having a zinc oxide film under a silver film and over a zinc stannate film may be enhanced by adding tin to a zinc target to provide a zinc oxide, tin oxide film, or a zinc stannate film. As used herein, "a chemical and electrical enhancement film" is a zinc oxide, tin oxide film and/or a zinc stannate film having zinc in the range of 60 to 90 weight percent and tin in the range of 10 to 40 weight percent. The chemical and electrical enhancement film of the invention may be used in place of zinc oxide films to enhance chemical durability of the coating stack while obtaining a silver film having low emissivity. By way of illustration, coated articles having a glass substrate/zinc stannate film/zinc oxide film/silver film/titanium metal primer film/zinc oxide film/zinc stannate film/zinc oxide film/zinc stannate film/titanium metal and/or titanium oxide or oxynitride protective overcoat may be chemically enhanced by using the chemical and electrical enhancement film of the invention for one or more or all of the zinc oxide film(s) of the above coating stack.

40 [0033] Another coated article includes glass substrate/zinc stannate film/zinc oxide film/silver film/titanium metal primer film/zinc oxide film/zinc stannate film/titanium metal and/or titanium oxide or oxynitride protective overcoat. As can now be appreciated, the chemical and electrical enhancement film of the invention may be substituted for one or more or all

of the zinc oxide film(s) of the above coating.

[0034] In the practice of the instant invention, a dielectric layer may include a zinc stannate film, and a chemical and electrical enhancement film. Where the chemical and electrical enhancement film is zinc stannate, the difference between the composition of the zinc stannate film and the zinc stannate film of the chemical and electrical enhancement film is at least 5 weight percent zinc. For example, and not limiting to the invention a zinc stannate film having 58 weight percent zinc and 42 weight percent tin may be used with a zinc stannate film (chemical and electrical enhancement film) having 63 to 90 weight percent zinc and 10 to 37 weight percent tin.

[0035] The discussion will now be directed to the embodiment of the invention to provide a coating stack that is chemically and mechanically durable and a coating stack that has reduced haze after subjecting the coating stack to elevated temperatures, e.g., but not limiting to the invention, above room temperature and below about 1350°F (732°C). As will be appreciated by those skilled in the art, the coatings discussed below are presented for illustration purposes only. The following Table 1 provides a few embodiments of coating stacks according to the invention and not according to the invention (*).

TABLE 1

Coating Samples	substrate	FILM												
		1	2	3	4	5	6	7	8	9	10	11	12	13
1 *	X	X	X	X	X		X						X	
2 *	X	X	X	X	X		X		X	X		X	X	
3 *	X	X		X	X	X	X		X	X		X	X	
4 *	X	X		X	X		X		X	X	X	X	X	
5 *	X	X	X	X	X	X	X		X	X		X	X	
6 *	X	X	X	X	X		X		X	X	X	X	X	
7 *	X	X		X	X	X	X		X	X	X	X	X	
8 *	X	X	X	X	X	X	X		X	X	X	X	X	
9 *	X	X	X	X	X	X	X	X	X	X	X	X	X	
10 *	X	X	X	X	X	X	X	X	X	X	X	X		X
11	X	X	X	X	X	X	X	X	X	X	X	X	X	X
12 *	X	X	X	X	X		X							X
13	X	X	X	X	X		X						X	X
Layers		A		B	C	D			E	F	G		H	
* not according to the invention														

[0036] The second column from the left is entitled "Substrate." The material of the substrate is not limiting to the invention and may be made of any material, e.g., glass, fiberglass, plastic, metal, wood or ceramic. The type of articles that are made in the preferred practice of the invention are transparencies for residential and commercial buildings, and land, air, space, above, on and below water vehicles, therefore, the substrate is preferably transparent and made of glass, and flexible and rigid plastics. Glass when used may be clear or tinted and made by any process including the float glass manufacturing process, and the type of glass is not limiting to the invention. It is expected that the coated article will be subjected to elevated temperatures; therefore, the substrate selected should be able to withstand the elevated temperatures. In our discussion, but not limiting to the invention, the substrates are glass sheets or pieces.

[0037] The columns numbered 1-13 are films, and the columns labeled A-H are layers, of coating stacks that incorporate features of the invention. The layers (see the bottom of the Table 1) include at least one film and as shown in the Table 1 up to 3 films. The layers A, D and G are dielectric layers. The index of refraction of the dielectric films of the Layers A, D and G is preferably greater than the index of refraction of the transparent substrate to anti-reflect the infrared reflection layer. The invention is not limited to the type of dielectric films that may be used in combination with the chemical and electrical enhancement film of the invention. Dielectric films that may be used in the practice of the invention include but are not limited to zinc oxide, tin oxide, silicon oxide, silicon nitride, and silicon oxynitride. It is preferred that films 1, 6 and 11 of the layers A, D and G, respectively are each a zinc stannate film having 52 weight percent zinc and 48

weight percent tin. The films 2, 5 and 7, and 10 of the layers A, D and G respectively may be a zinc oxide film, or a chemical and electrical enhancement film of the invention. Coating examples 12-13 of Table 1 are prophetic examples, but these coating examples show the presence of one or both of films 12 and/or 13 as layer H. Coating examples 12 and 13 are those with the least number of films which can have either or both of the protective films for the protective layer. Of course any of the other coating examples 2-8 can also have either or both for the H layer.

[0038] In the following discussion, the substrate is soda-lime-silicate clear glass and has an index of refraction about 1.5. As is known in the art, varying the thickness of the film and layers changes the color of the coated article, or may provide a coating with a neutral color. It is expected that in the practice of the invention, the dielectric layers and/or films have a thickness in the range of 600 ± 500 Angstroms. The thickness of the zinc oxide film or the chemical and electrical enhancement film should be sufficient to affect the crystal structure of the silver film to be deposited thereon.

[0039] The films 3 and 8 of layers B and E, respectively, are infrared reflecting films and may be of any material that reflects infrared energy, e.g., but not limiting to gold, silver and aluminum. In the practice of the invention silver is preferred. The thickness of the silver is not limiting to the invention and is selected to provide a transparent coating having low emissivity. Silver films having a thickness of 200 ± 150 Å and preferably 100 ± 25 Å may be used in the practice of the invention.

[0040] The films 4 and 9 of the layers C and F, respectively, are primer films which have the function of (1) protecting the infrared metal layer from oxidizing during sputtering of the dielectric films, (2) protecting the infrared reflecting layer during high temperature processing, (3) reducing haze formation in the coating stack during heating, and/or (4) providing the coating stack with mechanical durability for shipping the coated article. Primer films may be any of the type known in the art, e.g., metals such as titanium or ceramic, of the type disclosed in U.S. Patent Application Serial No. 09/215,560, filed December 8, 1998, the disclosure of which is hereby incorporated by reference. In the practice of the invention, the primer layer is preferably titanium.

[0041] Films 12 and 13 of the layer H is or are protective films to provide additional chemical and mechanical durability for the coating stack during shipping and storage. The protective films are thin film sputter coating of metals or silicon and metal or silicon oxy-materials where the metals and metal oxy-materials that may be used can be titanium, titanium dioxide, titanium oxynitride, zirconium, zirconium oxides, zirconium oxynitrides, niobium, niobium oxides, niobium oxynitrides, tantalum, tantalum oxide, tantalum oxynitride, chromium, chromic oxides, chromic oxynitrides, nickel oxide and/or oxynitrides, and silicon oxide, silicon dioxide, silicon aluminum nitride and alloys, combinations or mixtures of any two or more of these including those like nickel chromium, silicon chromium, silicon chromium nickel, and silicon nickel. Also the aforementioned oxides can be oxynitrides. The aforementioned metals are useful as single films for the protective layer at numerous locations in a stack of layers when the stack of films is heat treated and the metals are converted by the heat to metal oxide films or metal oxynitride, films. The temperature of heating are those usually encountered in tempering and heating a substrate for shape-changing. When both the metal and the metal oxymaterial films are used either may be deposited first for the protective layer with the other film over the first deposited film for layer H. Generally the thickness of the films are for the metal film about 5 to about 60 Angstroms (Å), preferably about 10 to about 30 Å and most preferably 15 to 25 Å. The metal oxy film can have a thickness in the range from about 20 to about 50 Å, preferably 30 to 40 Å. Further, more than one protective film may be used. For example, but not limiting to the invention, a zinc oxide film over a titanium dioxide film may be used. The thickness of the Layer H is not limiting to the invention; however, the thickness should be thick enough to provide protection. The metal, metal oxy films can be deposited by any method known to those skilled in the art. Also part of the metal film can be oxidized by heating rather than depositing a separate metal oxide film.

[0042] Before discussing in detail the Samples of the Table 1, the following background information is provided for a better appreciate of the invention.

[0043] Using zinc oxide film, as discussed above, provides a silver layer having resistivity and emissivity lower than a silver layer deposited on a zinc stannate layer having less than about 60 weight percent zinc and more than about 40 weight percent tin.

[0044] U.S.P.N. '001 discusses increasing the thickness of the primer layer to enhance the mechanical durability of the coated article to make the coated article shippable. More particularly, U.S.P.N. 001 discloses that it has been found that where the coated article will be exposed to heat treatment during its production, there is a point at which the primer layer may be made either too thin or too thick. Too thin a primer layer results in a lack of protection for the reflective, metallic film from oxidation at high temperature thus rendering the coated article unacceptable for heat treatment and in poor shear resistance which makes the article unsuitable for along distance shipment for later thermal processing. Too thick a primer layer results in the formation of an undesirable haze in the coated article after heat treatment, also rendering it unacceptable for heat treatment. However, a limitation is that these films after heating have haze.

[0045] It has been determined that by selecting dielectric films and primer layers that a coating stack can be made that has reduced haze after heating. For coated articles that are shipped but not heated, the primer layer should be thick enough to protect the silver during deposition of the overlying dielectric film or layer on the silver layer. A thickness of primer layers in the range of about 8 to 12 Angstroms is sufficient. The thickness of the primer layer is increased when

the primer layer is to protect the silver during heating of the coated article. A thickness of about $20 \pm 5 \text{ \AA}$ is acceptable.

[0046] For a coated article that is shippable and heatable with reduced haze, the thickness of the primer film is adjusted to compliment the dielectric layer or film arrangement. In accordance with the teachings of the invention, primer layer thickness in the range of 18-32 Angstroms (\AA) and preferably 18-40 \AA is acceptable to provide a coating stack with

reduced haze after heating. The following Examples illustrate the invention.
 [0047] In the following discussion, the thickness of the metal primer layer is as deposited. As can be appreciated, the thickness increases after heating, changing a portion of the titanium metal primer film to titanium oxide. A method that will be referred to as the "XRF Method" is discussed in U.S.P.N. '001. In general the XRF Method is used to measure the thickness of metal layers. The XRF Method uses calibrated x-ray fluorescence instrument to measure the weight of the metal per unit area of the coating (namely, in $\mu\text{g}/\text{cm}^2$). The XRF Method makes the assumption that the metal film is as dense as its bulk form. With this assumption, the metal film's measured weight per unit area is then converted to a thickness in Angstroms, using its bulk density. For completeness sake, it should be noted that sputtered metal films are often less dense than their corresponding bulk metals, so that above described assumption is not always precisely correct, and the XRF Method may in some cases underestimate the thickness of the metal film due to this variation in density. Thus, for the thin metal films, the initial measurement of weight per unit area ($\mu\text{g}/\text{cm}^2$) is more accurate than the corresponding conversion to thickness based upon bulk density. Nonetheless, the XRF Method provides a useful approximation for comparing the relative thicknesses of the layers in coating.

[0048] In the following discussion, the thickness of the dielectric layers and/or films are given in ranges. As can be appreciated by those skilled in the art, the ranges are not limiting to the invention and the thickness may be selected to provide a coating stack of a desired color.

EXAMPLE 1 (not according to the invention)

[0049] This Example 1 is Sample 1 of the Table 1. Sample 1 is a coated article that is shippable and heatable. The coating is a high transmittance, low emissivity coated article having a single infrared, reflective layer. Product having the coating stack of Sample 1 is made and the coating stack includes:

a clear glass substrate; a dielectric, antireflective layer deposited on the substrate, the layer includes (1) a zinc stannate film having 52 weight percent zinc and 48 weight percent tin (hereinafter referred to as 52-48 zinc stannate film) and having a thickness of $260 \pm 40 \text{ \AA}$, and (2) a zinc stannate film having 90 weight percent zinc and 10 weight percent tin (hereinafter referred to as 90-10 zinc stannate film) and having a thickness of about $80 \pm 45 \text{ \AA}$;
 a silver film having a thickness of about $115 \pm 15 \text{ \AA}$ deposited on the 90-10 zinc stannate film,
 a titanium primer film having a thickness of $24-28 \text{ \AA}$ deposited on the metallic reflective film;
 a dielectric, antireflective upper layer deposited on the titanium primer film, the dielectric, antireflective upper film includes a 52-48 zinc stannate film having a thickness of about $230 \pm 60 \text{ \AA}$ deposited on the primer layer metal oxide, and
 a titanium oxide layer having a thickness of $36 \pm 7 \text{ \AA}$ deposited on the 52-48 zinc stannate layer or film.

EXAMPLE 2 (not according to the invention)

[0050] This Example 2 is Sample 2 of the Table 1. The coated article has been made and is shippable and heatable with reduced haze. The coated article includes a glass substrate/a layer of a 52-48 zinc stannate film having a thickness of about $230 \pm 40 \text{ \AA}$ and a zinc oxide film having a thickness of about $80 \pm 40 \text{ \AA}$; a silver film having a thickness of $110 \pm 10 \text{ \AA}$; a titanium metal primer film having a thickness of about 18 - 23 \AA and preferably 19.5 \AA ; a 52-48 zinc stannate film having a thickness of about $820 \pm 40 \text{ \AA}$; a silver film having a thickness of about $110 \pm 10 \text{ \AA}$; a metal primer having a thickness of about 18 - 31 \AA and preferably 25 \AA ; a 52-48 zinc stannate film having a thickness of about $200 \pm 20 \text{ \AA}$, and a titanium film having a thickness of about $29 \pm 3 \text{ \AA}$.

EXAMPLE 3 (not according to the invention)

[0051] This Example 3 is Sample 3 of the Stable 1. The coated article was not made; however, the following coated article is expected to be shippable and heatable with reduced haze. Example 3 includes a clear glass substrate; a dielectric, antireflective base layer deposited on the substrate includes a 52-48 zinc stannate film having a thickness of about $310 \pm 20 \text{ \AA}$ deposited on the glass substrate; a first silver film having a thickness of about $110 \pm 10 \text{ \AA}$ deposited on the 52-48 zinc stannate film; a first titanium primer film having a thickness of $18-29 \text{ \AA}$ deposited on the first silver film; a dielectric, antireflective intermediate layer deposited on the first primer film, the intermediate layer includes a zinc oxide film having a thickness of $80 \pm 40 \text{ \AA}$ deposited on the first primer film, a 52-48 zinc stannate film having a thickness of $740 \pm 40 \text{ \AA}$ deposited on the zinc oxide film; a second silver film having a thickness of about $110 \pm 10 \text{ \AA}$ deposited on

the 52-48 zinc stannate film of the intermediate layer; a second titanium primer film having a thickness of about 18-31Å deposited on the second silver film; a dielectric, antireflective upper layer deposited on the second primer film, the dielectric upper layer is a 52-48 zinc stannate film having a thickness of about $200 \pm 20\text{Å}$; and a titanium metal protective film having a thickness of about $29 \pm 3\text{Å}$, deposited on the 52-48 zinc stannate film of the dielectric upper layer.

EXAMPLE 4 (not according to the invention)

[0052] This Example 4 is Sample 4 of the Table 1. The coated article of Example 4 was made and is shippable and heatable with the heated, coated article having reduced haze. The coated article of this Example 4 includes a clear glass substrate; a 52-48 zinc stannate film having a thickness of $310 \pm 20\text{Å}$ deposited on the glass substrate; a first silver film having a thickness of $110 \pm 10\text{Å}$ deposited on the 52-48 zinc stannate film; a first titanium primer having a thickness of 18-29Å and preferably 22.5Å deposited on the first silver film; a 52-48 zinc stannate film having a thickness of about $820 \pm 40\text{Å}$ deposited on the first titanium film; a second silver film having a thickness of about $110 \pm 10\text{Å}$ deposited on the 52-48 zinc stannate film; a second titanium film having a thickness of 18-32Å and preferably 21.5Å is deposited on the second silver layer; a zinc oxide film having a thickness of $80 \pm 40\text{Å}$ deposited on the second titanium primer layer; a 52-48 zinc stannate film having a thickness of $120 \pm 40\text{Å}$ deposited on the zinc oxide film and a titanium overcoat film having a thickness of $29 \pm 3\text{Å}$ over the 52-48 zinc stannate film.

EXAMPLE 5 (not according to the invention)

[0053] This Example 5 is Sample 5 of the Table 1. The coated article was not made; however, it is expected that the coated article is suitable for shipment and heat treatment with the heated, coated article having reduced haze. The coated article of this Example 5 includes the films and layers similar to Example 3 except Sample 5 has a 52-48 zinc stannate film having a thickness of about $230 \pm 40\text{Å}$ deposited on the substrate and a zinc oxide film having a thickness of about $80 \pm 40\text{Å}$ deposited on the 52-48 zinc stannate film. The first titanium primer film on the first silver layer has a thickness of about 18-29Å; the second titanium primer film on the second silver layer has a thickness of about 18-31Å. The remaining layers of Sample 5 are as shown in the Table and have the same composition and thickness for the same films as described in Example 3.

EXAMPLE 6 (not according to the invention)

[0054] This Example 6 is Sample 6 of the Table 1 and was made and is shippable and heatable with the heated, coated article having reduced haze. The coated stack is similar to the coating stack of Example 2 except a zinc oxide film having a thickness of about $80 \pm 40\text{Å}$ is deposited on the second titanium primer and a 52-48 zinc stannate film having a thickness of $120 \pm 40\text{Å}$ is deposited on the zinc oxide film. The first titanium primer layer had a thickness of 19-26Å and preferably 19.5Å, and the second primer layer had a thickness of 21.5-31Å and preferably 25Å. The composition and thickness of the remaining films/layers for Example 6 as shown for Sample 6 in the Table are as described in Example 2.

EXAMPLE 7 (not according to the invention)

[0055] This Example 7 is Sample 7 of the Table 1 and was made and is shippable and heatable with the heated coating stack having reduced haze. The coating stack of Sample 7 is similar to the coating stack of Example 3 except a zinc oxide film having a thickness of about $80 \pm 40\text{Å}$ was deposited on the second titanium film and a 52-48 zinc stannate film was deposited on the zinc oxide film. The first titanium primer layer had a thickness of about 22-26Å and preferably 22.5Å, and the second titanium primer layer had a thickness of about 18-25Å and preferably 21.5Å. The composition and thickness of the remaining films/layers for Example 7 as shown for Sample 7 on the Table are as described in Example 2.

EXAMPLE 8 (not according to the invention)

[0056] This Example 8 is Sample 8 of the Table. The coated article was made and is a coated article suitable for shipment and heat treatment with the heated coated articles having reduced haze. The coated article of this Example 8 is a coated stack deposited on a clear glass substrate. The coating thickness and order of the films is as follows with film 1 deposited on the glass substrate.

TABLE 2

Film No. from Table	Composition of the Film	Thickness of the Film
1	52-48 zinc stannate	230 ± 40Å
2	zinc oxide	80 ± 40Å
3	1 st silver	110 ± 30Å
4	1 st titanium primer	17-26Å, preferably 19.5Å
5	zinc oxide	80 ± 40Å
6	52-48 zinc stannate	740 ± 40Å
8	2 nd silver film	110 ± 30Å
9	titanium primer	18-31Å, preferably 28Å
10	2 nd zinc oxide	80 ± 40Å
11	52-48 zinc stannate	120 ± 40Å
12	titanium metal overcoat	29 ± 3Å

[0057] The coated glass having the above coating was used in the fabrication of automotive windshields. The coated glass was cut to size, heated to shape the coated glass, and thereafter laminated to another shaped glass to provide an automotive windshield. The transmittance of the laminate was greater than 70%, and reflects infrared energy. The windshield was made as is known in the art. Coated glass for use in automotive windshield was also made substituting 90-10 zinc stannate for the zinc oxide film. The coated article had film thickness in the ranges recited on Table 2.

[0058] As can be appreciated, the thickness of the primer layers presented in Table 2 can vary depending on cathode and sputtering equipment. For example, a shippable and heatable coating stack with reduced haze was made with a first titanium primer film having a thickness of 18 ± 0.5Å and the second titanium primer film having a thickness of 22 ± 1Å

EXAMPLE 9 (not according to the invention)

[0059] This Example 9 is Sample 9 of the Table and is a coated article that was made. The coated article was shippable and heatable with the heated, coated article having reduced haze. The coated article of this Example 9 is a coated stack deposited on a clear glass substrate. The coating thickness and order of the films is as follows with film 1 deposited on the glass substrate.

TABLE 3

Film No. from Table	Composition of the Film	Thickness of the Film
1	52-48 zinc stannate	230 ± 40Å
2	90-10 zinc stannate	80 ± 40Å
3	1 st silver	107 ± 30Å
4	1 st at titanium primer	17-24Å, preferably 21.5Å
5	90-10 zinc stannate	80 ± 40Å
6	52-48 zinc stannate	600 ± 100Å
7	90-10 zinc stannate	80 ± 30Å
8	2 nd silver	127 ± 30Å
9	titanium metal primer	20-26Å, preferably 22.5Å
10	90-10 zinc stannate	80 ± 40Å
11	52-48 zinc stannate	160 ± 60Å
12	titanium oxide overcoat	45 ± 15Å

[0060] As can now be appreciated, a 90-10 zinc stannate film, a zinc oxide film and a zinc oxide, tin oxide film may

be interchanged with one another and substituted for one another to obtain coated articles that are shippable and heatable with reduced haze. However, the 9-10 zinc stannate film is preferred.

Example 10 (not according to the invention), Example 11 (according to the invention)

[0061] Examples 10 and 11 are Samples 10 and 11 of the Table. These examples were similar to example 9 with the following exceptions. For Example 10 titanium metal was the overcoat and for Example 11 according to the invention titanium metal and titanium oxide were the overcoats. Example 11 was conducted in an alternative manner where the protective layer was first the titanium oxide film with the titanium film over top of it.

[0062] As can be appreciated, the thickness of the films is not limiting to the invention and may be selected to provide a coated article of a desired color as is known in the art. Further, the films of all examples of the invention may be interchanged to attain the features of the invention.

A complete discussion of heating the coated glass sheets to automotive windshields, residential and commercial windows and other transparencies was not given as such technology is known in the art and as can now be appreciated used in the practice of the invention.

[0063] The invention is not limited to the examples presented above and that various changes and alterations can be made without departing from broader aspects of the invention, as defined by the claims set forth below and by the range of equivalency allowed by law.

Claims

1. A coated article comprising:

(i) a substrate;

(ii) a first dielectric layer sputter deposited over the substrate (i), the layer (ii) comprising:

(iia) a first zinc stannate film deposited over the substrate (i) having zinc in weight percent range of equal to and greater than 10 and equal to and less than 90, and tin in the weight percent range of equal to and less than 90 and equal to and greater than 10, and

(iib) an electrical enhancing film deposited over the zinc stannate film (iia), the electrical enhancing film selected from the group of films consisting of zinc oxide, tin oxide film sputter deposited from a target having from 0.5 to 9.5 weight percent tin and from 99.5 to 90.5 weight percent zinc and a second zinc stannate film, wherein the composition of the first zinc stannate film (ia) is at least about 5 weight percent different than the composition of the second zinc stannate film, and

(iii) at least one infrared reflective layer over the first dielectric layer (ii);

(iv) optionally a first metal primer layer over the first infrared reflective layer (iii);

(v) optionally a second dielectric layer over a first metal primer layer (iv); and

(vi) at least one protective layer consisting of two films, wherein one film is selected from metals or silicon and the other film is selected from metal-oxy-or silicon-oxy-materials, wherein one of the films is deposited first with the other film deposited over the first deposited film, and where the metal is the same or different and selected from titanium; zirconium, niobium, tantalum, chromium, nickel and alloys thereof, and where the oxy-materials are selected from titanium oxides, titanium oxynitride, zirconium oxides, zirconium oxynitride, niobium oxides, niobium oxynitride, tantalum oxides, tantalum oxynitride, chromic oxides, chromic oxynitride, nickel oxide, nickel oxynitride, silicon oxide, silicon dioxide, silicon aluminium nitride.

2. The coated article of Claim 1, wherein the dielectric layer (ii) is a first dielectric layer and the infrared reflective layer (iii) is a first infrared reflective layer and the stack further including:

a second dielectric layer (v) over the primer layer (iv) and

(vii) a second infrared reflective layer over the second dielectric layer (v);

(viii) optionally a primer layer over the second infrared reflective layer (vii); and

the protective layer (vi) is an overcoat over the second dielectric layer (v).

3. The coated article of Claim 2, wherein the protective layer (vi) has at least two films in either order of metal or silicon

and metal oxy or silicon oxy material located between the second dielectric layer (v) on the second infrared reflective layer (vii) and a third dielectric layer (ix).

4. The coated article of claim 1, wherein the stack comprising:

- (i) a substrate;
- (ii) a first dielectric layer sputter deposited over the substrate (i), the layer (ii) comprising :
 - (iia) a first zinc stannate film deposited over the substrate (i) having zinc in weight percent range of equal to and greater than 10 and equal to and less than 90, and tin in the weight percent range of equal to and less than 90 and equal to and greater than 10, and
 - (iib) an electrical enhancing film deposited over the zinc stannate film (iia), the electrical enhancing film selected from the group of films consisting of zinc oxide, tin oxide film sputter deposited from a target having from 0.5 to 9.5 weight percent tin and from 99.5 to 90.5 weight percent zinc and a second zinc stannate film, wherein the composition of the first zinc stannate film (ia) is at least about 5 weight percent different than the composition of the second zinc stannate film, and
- (iii) an infrared reflective layer deposited on the dielectric layer (ii),
- (iv) a metal primer layer over the infrared reflective layer (iii);
- (v) a second dielectric layer over the primer layer (iv); and
- (vi) a protective layer of at least two films as defined in claim 1 deposited on the second dielectric layer (v).

5. A coated article of claim 1, wherein the stack comprising:

- (i) a substrate;
- (ii) a first dielectric layer sputter deposited over the substrate (i);
- (iii) a first infrared reflective layer over the first dielectric layer (ii);
- (iv) a first metal primer layer over the first infrared reflective layer (iii);
- (v) a second dielectric layer over the first metal primer layer (iv), the second dielectric layer (v) having
 - (va) a first dielectric film selected from the group consisting of zinc oxide, tin oxide film sputter deposited from a target having from 0.5 to 9.5 weight percent tin and from 99.5 to 90.5 weight percent zinc and a first zinc stannate film, and
 - (vb) a second dielectric film the second dielectric film having a composition different than the first dielectric film of the second dielectric layer ;
- (vii) a second infrared reflective layer over the second dielectric layer (v);
- (viii) a second metal primer layer over the second infrared reflective layer (vii);
- (ix) a third dielectric layer over the second metal primer layer (ix); and
- (vi) a protective layer of at least two films as defined in claim 1 deposited on the third dielectric layer (ix),

6. A coated article of claim 1, wherein the stack comprising:

- (i) a substrate;
- (ii) a first dielectric layer sputter deposited over the substrate (i);
- (iii) a first infrared reflective layer over the first dielectric layer (ii);
- (iv) a first metal primer layer over the first infrared reflective layer (iii);
- (v) a second dielectric layer over the first metal primer layer (iv);
- (vii) a second infrared reflective layer over the second dielectric layer (v);
- (viii) a second metal primer layer over the second infrared reflective layer,
- (ix) a third dielectric layer having
 - (ixa) a first dielectric film selected from the group consisting of zinc oxide film; zinc oxide, tin oxide film deposited from a target having from 0.5 to 9.5 weight percent tin and from 99.5 to 90.5 weight percent zinc ; a first zinc stannate film and
 - (ixb) a second dielectric film overlying the first dielectric film (ixa), the second dielectric film having a composition different from the first dielectric film (ixa); and

(vi) a protective layer overlying the third dielectric layer (ix), where the protective layer is of at least two films as defined in claim 1.

7. A coated article of claim 1, wherein the stack comprising:

- (i) a substrate;
- (ii) a first dielectric layer over the substrate (i);
- (iii) a first infrared reflective layer over the first dielectric layer (ii);
- (iv) a first metal primer layer over the first infrared reflective layer (iii);
- (v) a second dielectric layer having

(va) a first dielectric film selected from the group consisting of zinc oxide, tin oxide film deposited from a target having from 0.5 to 9.5 weight percent tin and from 99.5 to 90.5 weight percent zinc and a first zinc stannate film, and

(vb) a second dielectric film overlying the first dielectric film (va) having a composition different than the first dielectric film (vb);

(vii) a second infrared reflective layer over the second dielectric layer (v);

(viii) a second primer layer over the second infrared reflective layer (vii);

(ix) a third dielectric layer over the second metal primer layer (viii), the third dielectric layer having

(ixa) a first dielectric film selected from the group consisting of a zinc oxide, tin oxide film deposited from a target having from 0.5 to 9.5 weight percent tin and from 99.5 to 90.5 weight percent zinc and a first zinc stannate film and

(ixb) a second dielectric film, having a composition different than the composition of the first dielectric film (ixa); and

(vi) a protective layer overlying the third dielectric layer (ix) where the protective layer is of at least two films as defined in claim 1.

8. The coated article of claim 4, wherein the metal of infrared reflective layer (iii) is silver and the silver is deposited on the zinc oxide, tin oxide film or the second zinc stannate film (iib).

9. The coated article of claim 4, wherein the dielectric layer (ii) is a first dielectric layer and the infrared reflective layer (iii) is a first infrared reflective layer and the metal primer layer (iv) is a first metal primer layer over the first infrared reflective metal layer (iii); and further including:

(vii) a second infrared reflective layer over the second dielectric layer (v);

(viii) a second metal primer layer over the second infrared reflective layer (vii);

(ix) a third dielectric layer over the second metal primer layer (ix); and the protective layer (vi) is over the third dielectric layer (x).

10. The coated article of claims 4 and 6, wherein at least one of the second and third dielectric layers (v,ix) includes a zinc stannate film having 10-90 weight percent zinc and 90-10 weight percent tin.

11. The coated article of claim 4, wherein the second dielectric layer (v) comprising:

(va) a first dielectric film and

(vb) a zinc stannate film having zinc in the weight percent range of equal to and greater than 10 and equal to and less than 90 and tin in the weight percent range of equal to and greater than 10 and equal to and less than 90.

12. The coated article of claim 11, wherein the first dielectric film (va) of the second dielectric layer (v) comprises a zinc oxide film; a zinc oxide, tin oxide film deposited from a target having from 0.5 to 9.5 weight percent tin and from 99.5 to 90.5 weight percent zinc or a zinc stannate film having a composition different than the composition of the zinc stannate film (vb) of the second dielectric layer (v).

13. The coated article of claim 12, wherein the zinc stannate film (va) of the second dielectric layer (v) has zinc in the weight percent range of equal to and greater than 60 and equal to and less than 90 and tin in the weight percent of

equal to and greater than 10 and equal to and less than 40, and the third dielectric layer (ix) is a zinc stannate film.

14. The coated article of claims 5 to 9, wherein the third dielectric layer (ix) comprising

5 (ixa) a first dielectric film and
 (ixb) a zinc stannate film having zinc in a weight percent range of equal to and greater than 10 and equal to and less than 90 and tin within the weight percent range of equal to and less than 90 and equal to and greater than 10.

10 15. The coated article of claim 14, wherein the first dielectric film (ixa) of the third dielectric layer (ix) is selected from the group consisting of a zinc oxide film; a zinc oxide, tin oxide film deposited from a target having from 0.5 to 9.5 weight percent tin and from 99.5 to 90.5 weight percent zinc or a zinc stannate film having a composition different than the composition of the first zinc stannate film (ixb) of third dielectric layer (ix).

15 16. The coated article of claim 15, wherein the zinc stannate film (ixa) of the third dielectric layer (ix) has zinc in the weight percent range of equal to and greater than 60 and equal to and less than 90 and tin in the weight percent range of equal to and greater than 10 and equal to and less than 40.

17. The coated article of claims 5 and 7, wherein the second dielectric layer (v) comprising :

20 (va) a first dielectric film and
 (vb) a zinc stannate film having zinc in the weight percent range of equal to and greater than 10 and equal to and less than 90 and tin in the weight percent range of equal to and greater than 10 and equal to and less than 90, and

25 the third dielectric layer (ix) comprising

30 (ixa) a first dielectric film and
 (ixb) a zinc stannate film having zinc within the weight percent range of equal to and greater than 10 and equal to and less than 90 and tin within the weight percent range of equal to and less than 90 and equal to and greater than 10.

35 18. The coated article of claim 17, wherein the first dielectric film (va) of the second dielectric layer (v) and the first dielectric film (ixa) of the third dielectric (ix) layer each has a film selected from the group consisting of zinc oxide film; zinc oxide, tin oxide film deposited from a target having from 0.5 to 9.5 weight percent tin and from 99.5 to 90.5 weight percent zinc or second zinc stannate film having a composition different than the composition of the zinc stannate film (vb, ixb) in the respective same second or third dielectric layer (v, ix).

40 19. The coated article of claim 10, wherein the zinc stannate film (iia,va) of the first and second dielectric layer (ii,v) each include zinc in the weight percent range of equal to and greater than 60 and equal to and less than 90 and tin in the weight percent range of equal to and greater than 10 and equal to and less than 40.

20. The coated article of claims 5, 7 or 11, wherein the second dielectric layer (v) further includes

45 (vc) a third dielectric film over the zinc stannate film (vb) of the second dielectric layer (v), wherein the third dielectric film (vc) is a film selected from a zinc oxide film, a zinc oxide, tin oxide film deposited from a target having from 0.5 to 9.5 weight percent tin and from 99.5 to 90.5 weight percent zinc and a zinc stannate film having a composition different than the composition of the zinc stannate film (vb) closest to the zinc stannate film (vc).

50 21. The coated article of claim 12, wherein the first and third dielectric films (va, vc) of the second dielectric layer (v) and the first dielectric film (ixa) of the third dielectric layer (ix) each include zinc in the weight percent range of equal to and greater than 60 and equal to and less than 90 and tin in the weight percent of equal to and greater than 10 and equal to and less than 40.

55 22. The coated article of any of Claims 1 to 21, wherein the protective layer (vi) has a thickness for the films of 0.0005 to 0.0060 μm (5 to 60 Å) for the metal or silicon film and 0.0020 to 0.050 μm (20 to 50 Å), for the oxy-material film.

23. The coated article of Claim 22, wherein the protective layer (vi) has a thickness for the films of 0.0010 to 0.0030 μm (10 to 30 Å) for the metal or silicon film and 0.0030 to 0.0040 μm (30 to 40 Å) for the oxy-material film.

24. The coated article of claim 4, where either the silicon, metal or the metal oxy material is the first film of the layer (vi).

25. The coated article of any of claims 1 to 24, wherein the substrate (i) is glass.

26. Use of the coated article of any of claims 1 to 25 as an automobile transparency.

27. Use of claim 26 wherein the automobile transparency is a windshield having a pair of glass sheets laminated together and one of the sheets is coated article according to any of claims 1 to 25.

28. The use of claim 27, wherein the coated article is heated to its bending temperature to provide a coated windshield blank and after heating the coating has reduced haze; and the coated blank is laminated to another piece of glass to provide the automobile windshield.

Patentansprüche

1. Beschichteter Gegenstand, umfassend:

(i) ein Substrat,

(ii) eine erste dielektrische Schicht, die durch Sputtern auf dem Substrat (i) abgeschieden ist, wobei die Schicht (ii) umfasst:

(iia) einen ersten Zinkstannatfilm, der über dem Substrat (i) abgeschieden ist und Zink in einem Gewichtsprozentbereich von gleich oder größer als 10 und gleich oder kleiner als 90 und Zinn in einem Gewichtsprozentbereich von gleich oder kleiner als 90 und gleich oder größer als 10 aufweist, und

(iib) einen elektrischen verstärkenden Film, der über dem Zinkstannatfilm (iia) abgeschieden ist, wobei der elektrische verstärkende Film ausgewählt ist aus der Gruppe von Filmen, bestehend aus Zinkoxid/Zinnoxid-Film, der durch Sputtern von einem Target mit 0,5 bis 9,5 Gew.-% Zinn und 99,5 bis 90,5 Gew.-% Zink abgeschieden ist, und einem zweiten Zinkstannatfilm, wobei die Zusammensetzung des ersten Zinkstannatfilms (ia) sich um mindestens etwa 5 Gew.-% von der Zusammensetzung des zweiten Zinkstannatfilms unterscheidet, und

(iii) mindestens eine infrarotreflektierende Schicht über der ersten dielektrische Schicht (ii),

(iv) optional eine erste Metall-Primerschicht über der ersten infrarotreflektierenden Schicht (iii),

(v) optional eine zweite dielektrische Schicht über einer ersten Metall-Primerschicht (iv) und

(vi) mindestens eine Schutzschicht, die aus zwei Filmen besteht, wobei ein Film aus Metallen oder Silicium ausgewählt ist und der andere Film aus Metall/Oxy- oder Silicium/Oxy-Materialien ausgewählt ist, wobei einer der Filme zuerst und der andere Film über dem ersten abgeschiedenen Film abgeschieden wird und wobei das Metall das gleiche oder ein unterschiedliches ist und ausgewählt ist aus Titan, Zirconium, Niobium, Tantal, Chrom, Nickel und Legierungen derselben und wobei die Oxy-Materialien ausgewählt sind aus Titanoxiden, Titanoxynitrid, Zirconiumoxiden, Zirconiumoxynitrid, Niobiumoxiden, Niobiumoxynitrid, Tantaloxiden, Tantaloxynitrid, Chromoxiden, Chromoxynitrid, Nickeloxid, Nickeloxynitrid, Siliciumoxid, Siliciumdioxide, Siliciumaluminiumnitrid.

2. Beschichteter Gegenstand nach Anspruch 1, wobei die dielektrische Schicht (ii) eine erste dielektrische Schicht ist und die infrarotreflektierende Schicht (iii) eine erste infrarotreflektierende Schicht ist und der Stapel ferner umfasst:

eine zweite dielektrische Schicht (v) über der Primerschicht (iv) und

(vii) eine zweite infrarotreflektierende Schicht über der zweiten dielektrische Schicht (v),

(viii) optional eine Primerschicht über der zweiten infrarotreflektierenden Schicht (vii) und

die Schutzschicht (vi) ein Überzug über der zweiten dielektrischen Schicht (v) ist.

3. Beschichteter Gegenstand nach Anspruch 2, wobei die Schutzschicht (vi) mindestens zwei Filme in beliebiger

Reihenfolge aus Metall oder Silicium und Metall/Oxy- oder Silicium/Oxy-Materialien aufweist, die zwischen der zweiten dielektrischen Schicht (v) auf der zweiten infrarotreflektierenden Schicht (vii) und einer dritten dielektrischen Schicht (ix) angeordnet sind.

5 4. Beschichteter Gegenstand nach Anspruch 1, wobei der Stapel umfasst:

- (i) ein Substrat,
- (ii) eine erste dielektrische Schicht, die durch Sputtern auf dem Substrat (i) abgeschieden ist, wobei die Schicht (ii) umfasst:

10 (iia) einen ersten Zinkstannatfilm, der auf dem Substrat (i) abgeschieden ist und Zink in einem Gewichtsprozentbereich von gleich oder größer als 10 und gleich oder kleiner als 90 und Zinn in einem Gewichtsprozentbereich von gleich oder kleiner als 90 und gleich oder größer als 10 aufweist, und

15 (iib) einen elektrischen verstärkenden Film, der über dem Zinkstannatfilm (iia) abgeschieden ist, wobei der elektrische verstärkende Film ausgewählt ist aus der Gruppe von Filmen, bestehend aus Zinkoxid/Zinnoxid-Film, der durch Sputtern von einem Target mit 0,5 bis 9,5 Gew.-% Zinn und 99,5 bis 90,5 Gew.-% Zink abgeschieden ist, und einem zweiten Zinkstannatfilm, wobei die Zusammensetzung des ersten Zinkstannatfilms (ia) sich um mindestens etwa 5 Gew.-% von der Zusammensetzung des zweiten Zinkstannatfilms unterscheidet, und

20 (iii) eine infrarotreflektierende Schicht, die über der dielektrischen Schicht (ii) abgeschieden ist,
 (iv) eine Metall-Primerschicht über der infrarotreflektierenden Schicht (iii),
 (v) eine zweite dielektrische Schicht über der Primerschicht (iv) und
 25 (vi) eine Schutzschicht aus mindestens zwei Filmen wie in Anspruch 1 definiert, die auf der zweiten dielektrischen Schicht (v) abgeschieden ist.

5 5. Beschichteter Gegenstand nach Anspruch 1, wobei der Stapel umfasst:

- (i) ein Substrat,
- 30 (ii) eine erste dielektrische Schicht, die durch Sputtern auf dem Substrat (i) abgeschieden ist,
- (iii) eine erste infrarotreflektierende Schicht über der ersten dielektrischen Schicht (ii),
- (iv) eine erste Metall-Primerschicht über der ersten infrarotreflektierenden Schicht (iii),
- (v) eine zweite dielektrische Schicht über der ersten Metall-Primerschicht (iv), wobei die zweite dielektrische Schicht (v)

35 (va) einen ersten dielektrischen Film ausgewählt aus der Gruppe bestehend aus Zinkoxid/Zinnoxid-Film, der durch Sputtern von einem Target mit 0,5 bis 9,5 Gew.-% Zinn und 99,5 bis 90,5 Gew.-% Zink abgeschieden ist, und einem ersten Zinkstannatfilm und

40 (vb) einen zweiten dielektrischen Film, wobei der zweite dielektrische Film eine Zusammensetzung aufweist, die sich vom ersten dielektrischen Film der zweiten dielektrischen Schicht unterscheidet,

umfasst,

- (vii) eine zweite infrarotreflektierende Schicht über der zweiten dielektrischen Schicht (v),
- (viii) eine zweite Metall-Primerschicht über der zweiten infrarotreflektierenden Schicht (vii),
- 45 (ix) eine dritte dielektrische Schicht über der zweiten Metall-Primerschicht (ix) und
- (vi) eine Schutzschicht aus mindestens zwei Filmen wie in Anspruch 1 definiert, die auf der dritten dielektrischen Schicht (ix) abgeschieden ist.

50 6. Beschichteter Gegenstand nach Anspruch 1, wobei der Stapel umfasst:

- (i) ein Substrat,
- (ii) eine erste dielektrische Schicht, die durch Sputtern auf dem Substrat (i) abgeschieden ist,
- (iii) eine erste infrarotreflektierende Schicht über der ersten dielektrischen Schicht (ii),
- (iv) eine erste Metall-Primerschicht über der ersten infrarotreflektierenden Schicht (iii),
- 55 (v) eine zweite dielektrische Schicht über der ersten Metall-Primerschicht (iv),
- (vii) eine zweite infrarotreflektierende Schicht über der zweiten dielektrischen Schicht (v),
- (viii) eine zweite Metall-Primerschicht über der zweiten infrarotreflektierenden Schicht,
- (ix) eine dritte dielektrische Schicht umfassend

(ixa) einen ersten dielektrischen Film ausgewählt aus der Gruppe bestehend aus Zinkoxid/Zinnoxid-Film, der durch Sputtern von einem Target mit 0,5 bis 9,5 Gew.-% Zinn und 99,5 bis 90,5 Gew.-% Zink abgeschieden ist, und einem ersten Zinkstannatfilm und
 (ixb) einen zweiten dielektrischen Film, der über dem ersten dielektrischen Film (ixa) liegt, wobei der zweite dielektrische Film eine Zusammensetzung aufweist, die sich vom ersten dielektrischen Film (ixa) unterscheidet,

(vi) eine Schutzschicht, die über der dritten dielektrischen Schicht (ix) liegt, wobei die Schutzschicht aus mindestens zwei Filmen wie in Anspruch 1 definiert besteht.

7. Beschichteter Gegenstand nach Anspruch 1, wobei der Stapel umfasst:

- (i) ein Substrat,
- (ii) eine erste dielektrische Schicht über dem Substrat (i),
- (iii) eine erste infrarotreflektierende Schicht über der ersten dielektrischen Schicht (ii),
- (iv) eine erste Metall-Primerschicht über der ersten infrarotreflektierenden Schicht (iii),
- (v) eine zweite dielektrische Schicht umfassend

(va) einen ersten dielektrischen Film ausgewählt aus der Gruppe bestehend aus Zinkoxid/Zinnoxid-Film, der von einem Target mit 0,5 bis 9,5 Gew.-% Zinn und 99,5 bis 90,5 Gew.-% Zink abgeschieden ist, und einem ersten Zinkstannatfilm, und

(vb) einen zweiten dielektrischen Film, der über dem ersten dielektrischen Film (va) liegt und eine Zusammensetzung aufweist, die sich vom ersten dielektrischen Film (vb) unterscheidet,

- (vii) eine zweite infrarotreflektierende Schicht über der zweiten dielektrischen Schicht (v),
- (viii) eine zweite Primerschicht über der zweiten infrarotreflektierenden Schicht (vii),
- (ix) eine dritte dielektrische Schicht über der zweiten Metall-Primerschicht (viii), wobei die dritte dielektrische Schicht aufweist:

(ixa) einen ersten dielektrischen Film ausgewählt aus der Gruppe bestehend aus Zinkoxid/Zinnoxid-Film, der von einem Target mit 0,5 bis 9,5 Gew.-% Zinn und 99,5 bis 90,5 Gew.-% Zink abgeschieden ist, und einem ersten Zinkstannatfilm und

(ixb) einen zweiten dielektrischen Film, der eine Zusammensetzung aufweist, die sich vom ersten dielektrischen Film (ixa) unterscheidet, und

(vi) eine Schutzschicht, die über der dritten dielektrischen Schicht (ix) liegt, wobei die Schutzschicht aus mindestens zwei Filmen wie in Anspruch 1 definiert besteht.

8. Beschichteter Gegenstand nach Anspruch 4, wobei das Metall der infrarotreflektierenden Schicht (iii) Silber ist und das Silber auf dem Zinkoxid/Zinnoxid-Film oder dem zweiten Zinkstannatfilm (iib) abgeschieden ist.

9. Beschichteter Gegenstand nach Anspruch 4, wobei die dielektrische Schicht (ii) eine erste dielektrische Schicht ist und die infrarotreflektierende Schicht (iii) eine erste infrarotreflektierende Schicht ist und die Metall-Primerschicht (iv) eine erste Metall-Primerschicht über der ersten infrarotreflektierenden Metallschicht (iii) ist, und der ferner umfasst:

- (vii) eine zweite infrarotreflektierende Schicht über der zweiten dielektrischen Schicht (v),
- (viii) eine zweite Metall-Primerschicht über der zweiten infrarotreflektierenden Schicht (vii),
- (ix) eine dritte dielektrische Schicht über der zweiten Metall-Primerschicht (ix) und wobei die Schutzschicht (vi) über der dritten dielektrischen Schicht (x) angeordnet ist.

10. Beschichteter Gegenstand nach Anspruch 4 und 6, wobei mindestens eine von der zweiten und dritten dielektrische Schicht (v, ix) einen Zinkstannatfilm mit 10-90 Gew.-% Zink und 90-10 Gew.-% Zinn umfasst.

11. Beschichteter Gegenstand nach Anspruch 4, wobei die zweite dielektrische Schicht (v) umfasst:

- (va) einen ersten dielektrischen Film und
- (vb) einen Zinkstannatfilm mit Zink in einem Gewichtsprozentbereich von gleich oder größer als 10 und gleich oder kleiner als 90 und Zinn in einem Gewichtsprozentbereich von gleich oder größer als 10 und gleich oder

kleiner als 90

- 5 12. Beschichteter Gegenstand nach Anspruch 11, wobei der erste dielektrische Film (va) der zweiten dielektrischen Schicht (v) einen Zinkoxidfilm, einen Zinkoxid/Zinnoxid-Film, der aus einem Target mit 0,5 bis 9,5 Gew.-% Zinn und 99,5 bis 90,5 Gew.-% Zink abgeschieden ist, oder einen Zinkstannatfilm mit einer Zusammensetzung, die sich von der Zusammensetzung des Zinkstannatfilms (vb) der zweiten dielektrischen Schicht (v) unterscheidet, enthält.
- 10 13. Beschichteter Gegenstand nach Anspruch 12, wobei der Zinkstannatfilm (va) der zweiten dielektrischen Schicht (v) Zink in einem Gewichtsprozentbereich von gleich oder größer als 60 und gleich oder kleiner als 90 und Zinn in dem Gewichtsprozentbereich von gleich oder größer als 10 und gleich oder kleiner als 40 enthält und die dritte dielektrische Schicht (ix) ein Zinkstannatfilm ist.
14. Beschichteter Gegenstand nach Ansprüchen 5 bis 9, wobei die dritte dielektrische Schicht (ix) umfasst:
- 15 (ixa) einen ersten dielektrischen Film and
(ixb) einen Zinkstannatfilm mit Zink in einem Gewichtsprozentbereich von gleich oder größer als 10 und gleich oder kleiner als 90 und Zinn in einem Gewichtsprozentbereich von gleich oder kleiner als 90 und gleich oder größer als 10 aufweist.
- 20 15. Beschichteter Gegenstand nach Anspruch 14, wobei der erste dielektrische Film (ixa) der dritten dielektrischen Schicht (ix) ausgewählt ist aus der Gruppe bestehend aus einem Zinkoxidfilm, einen Zinkoxid/Zinnoxid-Film, der aus einem Target mit 0,5 bis 9,5 Gew.-% Zinn und 99,5 bis 90,5 Gew.-% Zink abgeschieden ist, oder einem Zinkstannatfilm mit einer Zusammensetzung, die sich von der Zusammensetzung des ersten Zinkstannatfilms (ixb) der dritten dielektrischen Schicht (ix) unterscheidet.
- 25 16. Beschichteter Gegenstand nach Anspruch 15, wobei der Zinkstannatfilm (ixa) der dritten dielektrischen Schicht (ix) Zink in einem Gewichtsprozentbereich von gleich oder größer als 60 und gleich oder kleiner als 90 und Zinn in dem Gewichtsprozentbereich von gleich oder größer als 10 und gleich oder kleiner als 40 enthält.
- 30 17. Beschichteter Gegenstand nach Ansprüchen 5 und 7, wobei die zweite dielektrische Schicht (v)
- (va) einen ersten dielektrischen Film und
(vb) einen Zinkstannatfilm mit Zink in einem Gewichtsprozentbereich von gleich oder größer als 10 und gleich oder kleiner als 90 und Zinn in dem Gewichtsprozentbereich von gleich oder größer als 10 und gleich oder
35 kleiner als 90
- umfasst und wobei dritte dielektrische Schicht (ix)
- (ixa) einen ersten dielektrischen Film und
40 (ixb) einen Zinkstannatfilm mit Zink in einem Gewichtsprozentbereich von gleich oder größer als 10 und gleich oder kleiner als 90 und Zinn in dem Gewichtsprozentbereich von gleich oder kleiner als 90 und gleich oder größer als 10
- umfasst.
- 45 18. Beschichteter Gegenstand nach Anspruch 17, wobei der erste dielektrische Film (va) der zweiten dielektrischen Schicht (v) und der erste dielektrische Film (ixa) der dritten dielektrischen Schicht (ix) jeweils einen Film aufweisen, ausgewählt aus der Gruppe bestehend aus Zinkoxidfilm, Zinkoxid/Zinnoxid-Film, der aus einem Target mit 0,5 bis 9,5 Gew.-% Zinn und 99,5 bis 90,5 Gew.-% Zink abgeschieden ist, oder einem zweiten Zinkstannatfilm mit einer
50 Zusammensetzung, die sich von der Zusammensetzung des Zinkstannatfilms (vb, ixb) in der entsprechenden gleichen zweiten oder dritten dielektrischen Schicht (v, ix) unterscheidet.
19. Beschichteter Gegenstand nach Anspruch 10, wobei der Zinkstannatfilm (iia, va) der ersten und zweiten dielektrischen Schicht (ii, v) jeweils Zink in einem Gewichtsprozentbereich von gleich oder größer als 60 und gleich oder
55 kleiner als 90 und Zinn in einem Gewichtsprozentbereich von gleich oder größer als 10 und gleich oder kleiner als 40 enthält.
20. Beschichteter Gegenstand nach Ansprüchen 5, 7 oder 11, wobei die zweite dielektrische Schicht (v) ferner umfasst:

(vc) einen dritten dielektrischen Film über dem Zinkstannatfilm (vb) der zweiten dielektrischen Schicht (v), wobei der dritte dielektrische Film (vc) ein Film ist, der ausgewählt ist aus einem Zinkoxidfilm, einem Zinkoxid/Zinnoxid-Film, der aus einem Target mit 0,5 bis 9,5 Gew.-% Zinn und 99,5 bis 90,5 Gew.-% Zink abgeschieden ist, und einem Zinkstannatfilm mit einer Zusammensetzung, die sich von der Zusammensetzung des Zinkstannatfilms (vb), der dem Zinkstannatfilm (vc) am nächsten ist, unterscheidet.

21. Beschichteter Gegenstand nach Anspruch 12, wobei der erste und dritte dielektrische Film (va, vc) der zweiten dielektrischen Schicht (v) und der erste dielektrische Film (ixa) der dritten dielektrischen Schicht (ix) jeweils Zink in einem Gewichtsprozentbereich von gleich oder größer als 60 und gleich oder kleiner als 90 und Zinn in einem Gewichtsprozentbereich von gleich oder größer als 10 und gleich oder kleiner als 40 enthalten.

22. Beschichteter Gegenstand nach einem der Ansprüche 1 bis 21, wobei die Schutzschicht (vi) eine Dicke der Filme von 0,0005 bis 0,0060 μm (5 bis 60 Å) für den Metall- oder Siliciumfilm und von 0,0020 bis 0,050 μm (20 bis 50 Å) für den Oxy-Material-Film aufweist.

23. Beschichteter Gegenstand nach Anspruch 22, wobei die Schutzschicht (vi) eine Dicke der Filme von 0,0010 to 0,0030 μm (10 bis 30 Å) für den Metall- oder Siliciumfilm und von 0,0030 bis 0,0040 μm (30 bis 40 Å) für den Oxy-Materialfilm aufweist.

24. Beschichteter Gegenstand nach Anspruch 4, wobei entweder das Silicium, Metall oder das Metall/Oxy-Material der erste Film der Schicht (vi) ist.

25. Beschichteter Gegenstand nach einem der Ansprüche 1 bis 24, wobei das Substrat (i) Glas ist.

26. Verwendung des beschichteten Gegenstands nach einem der Ansprüche 1 bis 25 als ein Automobilfenster.

27. Verwendung nach Anspruch 26, wobei das Automobilfenster eine Windschutzscheibe mit einem Paar Glasscheiben, die miteinander laminiert sind, ist und eine der Scheiben ein beschichteter Gegenstand nach einem der Ansprüche 1 bis 25 ist.

28. Verwendung nach Anspruch 27, wobei der beschichtete Gegenstand auf seine Biegetemperatur erwärmt wird, um einen beschichteten Windschutzscheibenrohling bereitzustellen, und die Beschichtung nach Erwärmung verringerte Trübung aufweist und der beschichtete Rohling mit einem anderen Stück Glas laminiert wird, um die Automobilwindschutzscheibe bereitzustellen.

Revendications

1. Article revêtu comprenant :

(i) un substrat ;

(ii) une première couche diélectrique déposée par pulvérisation sur le substrat (i), la couche (ii) comprenant :

(iia) un premier film de stannate de zinc déposé sur le substrat (i) ayant du zinc dans une plage de pourcentage en poids supérieure ou égale à 10 et inférieure ou égale à 90 et de l'étain dans la plage de pourcentage en poids inférieure ou égale à 90 et supérieure ou égale à 10, et

(iib) un film de renforcement électrique déposé sur le film de stannate de zinc (iia), le film de renforcement électrique étant choisi dans le groupe de films constitué d'un film d'oxyde de zinc et d'oxyde d'étain déposé par pulvérisation à partir d'une cible ayant 0,5 à 9,5 pour cent en poids d'étain et 99,5 à 90,5 pour cent en poids de zinc et d'un deuxième film de stannate de zinc, dans lequel la composition du premier film de stannate de zinc (ia) est différente d'au moins environ 5 pour cent en poids par rapport à la composition du deuxième film de stannate de zinc, et

(iii) au moins une couche réfléchissant l'infrarouge sur la première couche diélectrique (ii) ;

(iv) éventuellement une première couche de fond métallique sur la première couche réfléchissant l'infrarouge (iii) ;

(v) éventuellement une deuxième couche diélectrique sur une première couche de fond métallique (iv) ; et

(vi) au moins une couche de protection constituée de deux films, dans laquelle un film est choisi parmi des

métaux ou du silicium et l'autre film est choisi parmi des matériaux de type métal-oxy ou silicium-oxy, l'un des films étant déposé en premier et l'autre film étant appliqué sur le premier film déposé, et où le métal est identique ou différent et est choisi parmi le titane, le zirconium, le niobium, le tantale, le chrome, le nickel et leurs alliages, et où les matériaux oxydés sont choisis parmi des oxydes de titane, l'oxynitride de titane, des oxydes de zirconium, l'oxynitride de zirconium, des oxydes de niobium, l'oxynitride de niobium, des oxydes de tantale, l'oxynitride de tantale, des oxydes de chrome, l'oxynitride de chrome, l'oxyde de nickel, l'oxynitride de nickel, l'oxyde de silicium, le dioxyde de silicium et le nitrure d'aluminium et de silicium.

2. Article revêtu selon la revendication 1, dans lequel la couche diélectrique (ii) est une première couche diélectrique, et la couche réfléchissant l'infrarouge (iii) est une première couche réfléchissant l'infrarouge et l'empilement comprend en outre :

une deuxième couche diélectrique (v) sur la couche de fond (iv) et

- (vii) une deuxième couche réfléchissant l'infrarouge sur la deuxième couche diélectrique (v) ;
 (viii) éventuellement une couche de fond sur la deuxième couche réfléchissant l'infrarouge (vii) ;
 et

la couche de protection (vi) est une couche de finition sur la deuxième couche diélectrique (v).

3. Article revêtu selon la revendication 2, dans lequel la couche de protection (vi) a au moins deux films constitués, selon un ordre quelconque, de métal ou de silicium et de matériau de type métal-oxy ou silicium-oxy, situés entre la deuxième couche diélectrique (v) appliquée sur la deuxième couche réfléchissant l'infrarouge (vii) et une troisième couche diélectrique (ix).

4. Article revêtu selon la revendication 1, dans lequel l'empilement comprend :

- (i) un substrat ;
 (ii) une première couche diélectrique déposée par pulvérisation sur le substrat (i), la couche (ii) comprenant :

(iia) un premier film de stannate de zinc déposé sur le substrat (i) contenant du zinc dans une plage de pourcentage en poids supérieure ou égale à 10 et inférieure ou égale à 90 et de l'étain dans la plage de pourcentage en poids inférieure ou égale à 90 et supérieure ou égale à 10, et

(iib) un film de renforcement électrique déposé sur le film de stannate de zinc (iia), le film de renforcement électrique étant choisi dans le groupe de films comprenant un film d'oxyde de zinc et d'oxyde d'étain déposé par pulvérisation à partir d'une cible ayant 0,5 à 9,5 pour cent en poids d'étain et 99,5 à 90,5 pour cent en poids de zinc et d'un deuxième film de stannate de zinc, dans lequel la composition du premier film de stannate de zinc (ia) est différente d'au moins environ 5 pour cent en poids par rapport à la composition du deuxième film de stannate de zinc, et

- (iii) une couche réfléchissant l'infrarouge déposée sur la couche diélectrique (ii),
 (iv) une couche de fond métallique sur la couche réfléchissant l'infrarouge (iii) ;
 (v) une deuxième couche diélectrique sur la couche de fond (iv) ; et
 (vi) une couche de protection ayant au moins deux films, telle que définie selon la revendication 1, déposée sur la deuxième couche diélectrique (v).

5. Article revêtu selon la revendication 1, dans lequel l'empilement comprend :

- (i) un substrat ;
 (ii) une première couche diélectrique déposée par pulvérisation sur le substrat (i) ;
 (iii) une première couche réfléchissant l'infrarouge sur la première couche diélectrique (ii) ;
 (iv) une première couche de fond métallique sur la première couche réfléchissant l'infrarouge (iii) ;
 (v) une deuxième couche diélectrique sur la première couche de fond métallique (iv), la deuxième couche diélectrique (v) présentant :

(va) un premier film diélectrique choisi dans le groupe constitué d'un film d'oxyde de zinc et d'oxyde d'étain déposé par pulvérisation à partir d'une cible ayant 0,5 à 9,5 pour cent en poids d'étain et 99,5 à 90,5 pour cent en poids de zinc, et d'un premier film de stannate de zinc, et

(vb) un deuxième film diélectrique, le deuxième film diélectrique ayant une composition différente du premier film diélectrique de la deuxième couche diélectrique ;

- (vii) une deuxième couche réfléchissant l'infrarouge sur la deuxième couche diélectrique (v) ;
(viii) une deuxième couche de fond métallique sur la deuxième couche réfléchissant l'infrarouge (vii) ;
(ix) une troisième couche diélectrique sur la deuxième couche de fond métallique (ix) ; et
(vi) une couche de protection constituée d'au moins deux films, telle que définie selon la revendication 1, déposée sur la troisième couche diélectrique (ix).

6. Article revêtu selon la revendication 1, dans lequel l'empilement comprend :

- (i) un substrat ;
(ii) une première couche diélectrique déposée par pulvérisation sur le substrat (i) ;
(iii) une première couche réfléchissant l'infrarouge sur la première couche diélectrique (ii) ;
(iv) une première couche de fond métallique sur la première couche réfléchissant l'infrarouge (iii) ;
(v) une deuxième couche diélectrique sur la première couche de fond métallique (iv) ;
(vi) une deuxième couche réfléchissant l'infrarouge sur la deuxième couche diélectrique (v) ;
(viii) une deuxième couche de fond métallique sur la deuxième couche réfléchissant l'infrarouge ;
(ix) une troisième couche diélectrique comprenant :

(ixa) un premier film diélectrique choisi dans le groupe constitué d'un film d'oxyde de zinc ; d'un film d'oxyde de zinc et d'oxyde d'étain déposé par pulvérisation à partir d'une cible ayant 0,5 à 9,5 pour cent en poids d'étain et 99,5 à 90,5 pour cent en poids de zinc ; et d'un premier film de stannate de zinc, et
(ixb) un deuxième film diélectrique recouvrant le premier film diélectrique (ixa), le deuxième film diélectrique ayant une composition différente du premier film diélectrique (ixa) ; et

(vi) une couche de protection recouvrant la troisième couche diélectrique (ix), la couche de protection étant constituée d'au moins deux films, tels que définis dans la revendication 1.

7. Article revêtu selon la revendication 1, dans lequel l'empilement comprend :

- (i) un substrat ;
(ii) une première couche diélectrique déposée sur le substrat (i) ;
(iii) une première couche réfléchissant l'infrarouge sur la première couche diélectrique (ii) ;
(iv) une première couche de fond métallique sur la première couche réfléchissant l'infrarouge (iii) ;
(v) une deuxième couche diélectrique comprenant :

(va) un premier film diélectrique choisi dans le groupe constitué d'un film d'oxyde de zinc et d'oxyde d'étain déposé à partir d'une cible ayant 0,5 à 9,5 pour cent en poids d'étain et 99,5 à 90,5 pour cent en poids de zinc et d'un premier film de stannate de zinc, et
(vb) un deuxième film diélectrique recouvrant le premier film diélectrique (va) ayant une composition différente du premier film diélectrique (vb) ;

(vii) une deuxième couche réfléchissant l'infrarouge sur la deuxième couche diélectrique (v) ;
(viii) une deuxième couche de fond sur la deuxième couche réfléchissant l'infrarouge (vii) ;
(ix) une troisième couche diélectrique sur la deuxième couche de fond métallique (viii), la troisième couche diélectrique comprenant :

(ixa) un premier film diélectrique choisi dans le groupe constitué d'un film d'oxyde de zinc et d'oxyde d'étain déposé à partir d'une cible ayant 0,5 à 9,5 pour cent en poids d'étain et 99,5 à 90,5 pour cent en poids de zinc et d'un premier film de stannate de zinc, et
(ixb) un deuxième film diélectrique ayant une composition différente de la composition du premier film diélectrique (ixa) ; et

(vi) une couche de protection recouvrant la troisième couche diélectrique (ix), la couche de protection étant constituée d'au moins deux films tels que définis dans la revendication 1.

8. Article revêtu selon la revendication 4, dans lequel le métal de la couche réfléchissant l'infrarouge (iii) est l'argent

et l'argent est déposé sur le film d'oxyde de zinc et d'oxyde d'étain ou sur le deuxième film de stannate de zinc (iib).

5 9. Article revêtu selon la revendication 4, dans lequel la couche diélectrique (ii) est une première couche diélectrique et la couche réfléchissant l'infrarouge (iii) est une première couche réfléchissant l'infrarouge et la couche de fond métallique (iv) est une première couche de fond métallique appliquée sur la première couche métallique réfléchissant l'infrarouge (iii) ; et comprenant en outre :

- 10 (vii) une deuxième couche réfléchissant l'infrarouge sur la deuxième couche diélectrique (v) ;
(viii) une deuxième couche de fond métallique sur la deuxième couche réfléchissant l'infrarouge (vii) ;
(ix) une troisième couche diélectrique sur la deuxième couche de fond métallique (ix) ; et la couche de protection (vi) est appliquée sur la troisième couche diélectrique (x).

15 10. Article revêtu selon les revendications 4 et 6, dans lequel au moins l'une des deuxième et troisième couches diélectriques (v, ix) comporte un film de stannate de zinc ayant 10 à 90 pour cent en poids de zinc et 90 à 10 pour cent en poids d'étain.

11. Article revêtu selon la revendication 4, dans lequel la deuxième couche diélectrique (v) comprend :

- 20 (va) un premier film diélectrique et
(vb) un film de stannate de zinc ayant du zinc dans la plage de pourcentage en poids supérieure ou égale à 10 et inférieure ou égale à 90 et de l'étain dans la plage de pourcentage en poids supérieure ou égale à 10 et inférieure ou égale à 90.

25 12. Article revêtu selon la revendication 11, dans lequel le premier film diélectrique (va) de la deuxième couche diélectrique (v) comprend un film d'oxyde de zinc ; un film d'oxyde de zinc et d'oxyde d'étain déposé à partir d'une cible ayant 0,5 à 9,5 pour cent en poids d'étain et 99,5 à 90,5 pour cent en poids de zinc ou un film de stannate de zinc ayant une composition différente de la composition du film de stannate de zinc (vb) de la deuxième couche diélectrique (v).

30 13. Article revêtu selon la revendication 12, dans lequel le film de stannate de zinc (va) de la deuxième couche diélectrique (v) contient du zinc dans la plage de pourcentage en poids supérieure ou égale à 60 et inférieure ou égale à 90 et de l'étain dans la plage de pourcentage en poids supérieure ou égale à 10 et inférieure ou égale à 40, et la troisième couche diélectrique (ix) est un film de stannate de zinc.

35 14. Article revêtu selon les revendications 5 à 9, dans lequel la troisième couche diélectrique (ix) comprend :

- 40 (ixa) un premier film diélectrique et
(ixb) un film de stannate de zinc ayant du zinc dans la plage de pourcentage en poids supérieure ou égale à 10 et inférieure ou égale à 90 et de l'étain dans la plage de pourcentage en poids inférieure ou égale à 90 et supérieure ou égale à 10.

45 15. Article revêtu selon la revendication 14, dans lequel le premier film diélectrique (ixa) de la troisième couche diélectrique (ix) est choisi dans le groupe constitué d'un film d'oxyde de zinc ; d'un film d'oxyde de zinc et d'oxyde d'étain déposé à partir d'une cible ayant 0,5 à 9,5 pour cent en poids d'étain et 99,5 à 90,5 pour cent en poids de zinc ou d'un film de stannate de zinc ayant une composition différente de la composition du premier film de stannate de zinc (ixb) de la troisième couche diélectrique (ix).

50 16. Article revêtu selon la revendication 15, dans lequel le film de stannate de zinc (ixa) de la troisième couche diélectrique (ix) contient du zinc dans la plage de pourcentage en poids supérieure ou égale à 60 et inférieure ou égale à 90 et de l'étain dans la plage de pourcentage en poids supérieure ou égale à 10 et inférieure ou égale à 40.

17. Article revêtu selon les revendications 5 et 7, dans lequel la deuxième couche diélectrique (v) comprend :

- 55 (va) un premier film diélectrique et
(vb) un film de stannate de zinc contenant du zinc dans la plage de pourcentage en poids supérieure ou égale à 10 et inférieure ou égale à 90 et de l'étain dans la plage de pourcentage en poids supérieure ou égale à 10 et inférieure ou égale à 90, et

la troisième couche diélectrique (ix) comprenant :

(ixa) un premier film diélectrique et

(ixb) un film de stannate de zinc contenant du zinc dans la plage de pourcentage en poids supérieure ou égale à 10 et inférieure ou égale à 90 et de l'étain dans la plage de pourcentage en poids inférieure ou égale à 90 et supérieure ou égale à 10.

18. Article revêtu selon la revendication 17, dans lequel le premier film diélectrique (va) de la deuxième couche diélectrique (v) et le premier film diélectrique (ixa) de la troisième couche diélectrique (ix) ont chacun un film choisi dans le groupe constitué d'un film d'oxyde de zinc ; d'un film d'oxyde de zinc et d'oxyde d'étain déposé à partir d'une cible ayant 0,5 à 9,5 pour cent en poids d'étain et 99,5 à 90,5 pour cent en poids de zinc ou d'un deuxième film de stannate de zinc ayant une composition différente de la composition du film de stannate de zinc (vb, ixb) contenu dans les mêmes deuxième ou troisième couches diélectriques respectives (v, ix).

19. Article revêtu selon la revendication 10, dans lequel le film de stannate de zinc (iia, va) de la première et de la deuxième couche diélectrique (ii, v) comprend, respectivement, du zinc dans la plage de pourcentage en poids supérieure ou égale à 60 et inférieure ou égale à 90 et de l'étain dans la plage de pourcentage en poids supérieure ou égale à 10 et inférieure ou égale à 40.

20. Article revêtu selon les revendications 5, 7 ou 11, dans lequel la deuxième couche diélectrique (v) comprend en outre :

(vc) un troisième film diélectrique sur le film de stannate de zinc (vb) de la deuxième couche diélectrique (v), dans lequel le troisième film diélectrique (vc) est un film choisi parmi un film d'oxyde de zinc, un film d'oxyde de zinc et d'oxyde d'étain déposé à partir d'une cible ayant 0,5 à 9,5 pour cent en poids d'étain et 99,5 à 90,5 pour cent en poids de zinc et un film de stannate de zinc ayant une composition différente de la composition du film de stannate de zinc (vb) le plus proche du film de stannate de zinc (vc).

21. Article revêtu selon la revendication 12, dans lequel les premier et troisième films diélectriques (va, vc) de la deuxième couche diélectrique (v) et le premier film diélectrique (ixa) de la troisième couche diélectrique (ix) comportent chacun du zinc dans la plage de pourcentage en poids supérieure ou égale à 60 et inférieure ou égale à 90 et de l'étain en pourcentage en poids supérieure ou égale à 10 et inférieure ou égale à 40.

22. Article revêtu selon une quelconque des revendications 1 à 21, dans lequel la couche de protection (vi) présente une épaisseur pour les films de 0,0005 à 0,0060 μm (5 à 60 Å) pour le film de métal ou de silicium et de 0,0020 à 0,050 μm (20 à 50 Å) pour le film de matériau oxydé.

23. Article revêtu selon la revendication 22, dans lequel la couche de protection (vi) présente une épaisseur pour les films de 0,0010 à 0,0030 μm (10 à 30 Å) pour le film de métal ou de silicium et de 0,0030 à 0,0040 μm (30 à 40 Å) pour le film de matériau oxydé.

24. Article revêtu selon la revendication 4, dans lequel le silicium, le métal ou le matériau de type métal-oxy est le premier film de la couche (vi).

25. Article revêtu selon l'une quelconque des revendications 1 à 24, dans lequel le substrat (i) est du verre.

26. Utilisation de l'article revêtu selon l'une quelconque des revendications 1 à 25, sous la forme d'un article transparent pour automobile.

27. Utilisation selon la revendication 26, dans laquelle l'article transparent pour automobile est un pare-brise présentant une paire de feuilles de verre contrecollées ensemble et l'une des feuilles est l'article revêtu selon l'une quelconque des revendications 1 à 25.

28. Utilisation selon la revendication 27, dans laquelle l'article revêtu est chauffé à sa température de flexion de manière à produire une ébauche de pare-brise revêtu et, après chauffage, le revêtement présente un voile réduit et l'ébauche revêtue est contrecollée à une autre pièce de verre pour produire le pare-brise d'automobile.

REFERENCES CITED IN THE DESCRIPTION

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Patent documents cited in the description

- US 4610771 A **[0002]**
- US 5821001 A **[0003]**
- EP 803481 A **[0007]**
- GB 2311540 A **[0008]**
- US 4902580 A **[0009]**
- US 5059295 A **[0010]**
- WO 9958763 A **[0011]**
- US 02374698 A, Mehran Arbab, Russell C. Criss, Gary J. Marietti and Paul A. Medwick **[0030]**
- US 09023746 B **[0030]**
- US 21556098 A **[0040]**